

LAMINATE AND USE THEREOF

ABSTRACT

There is provided a laminate having a layer construction of first inorganic material layer/insulating layer/second inorganic material layer or a layer construction of inorganic material layer/insulating layer, wherein the insulating layer has a multi-layer structure of two or more resin layers. In this case, the ratio of the etching rate of the resin layer which has a higher etching rate to the etching rate of the resin layer which has a lower etching rate is in the range of 6 : 1 to 1 : 1.

Figure 3